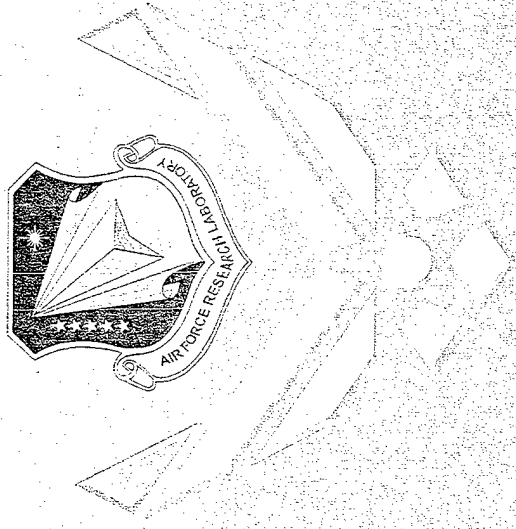


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The Specific Refractive Index Increments for POSS Polymers in Solution.

Sherly R. Largo[†], Timothy Haddad[†], Constance
Schlaefer* and Rene Gonzalez*

[†]ERC, Inc. – *Air Force Research Laboratory

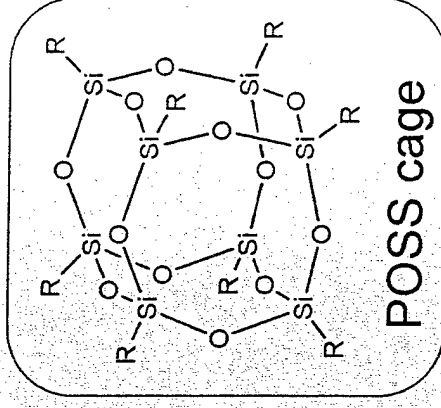
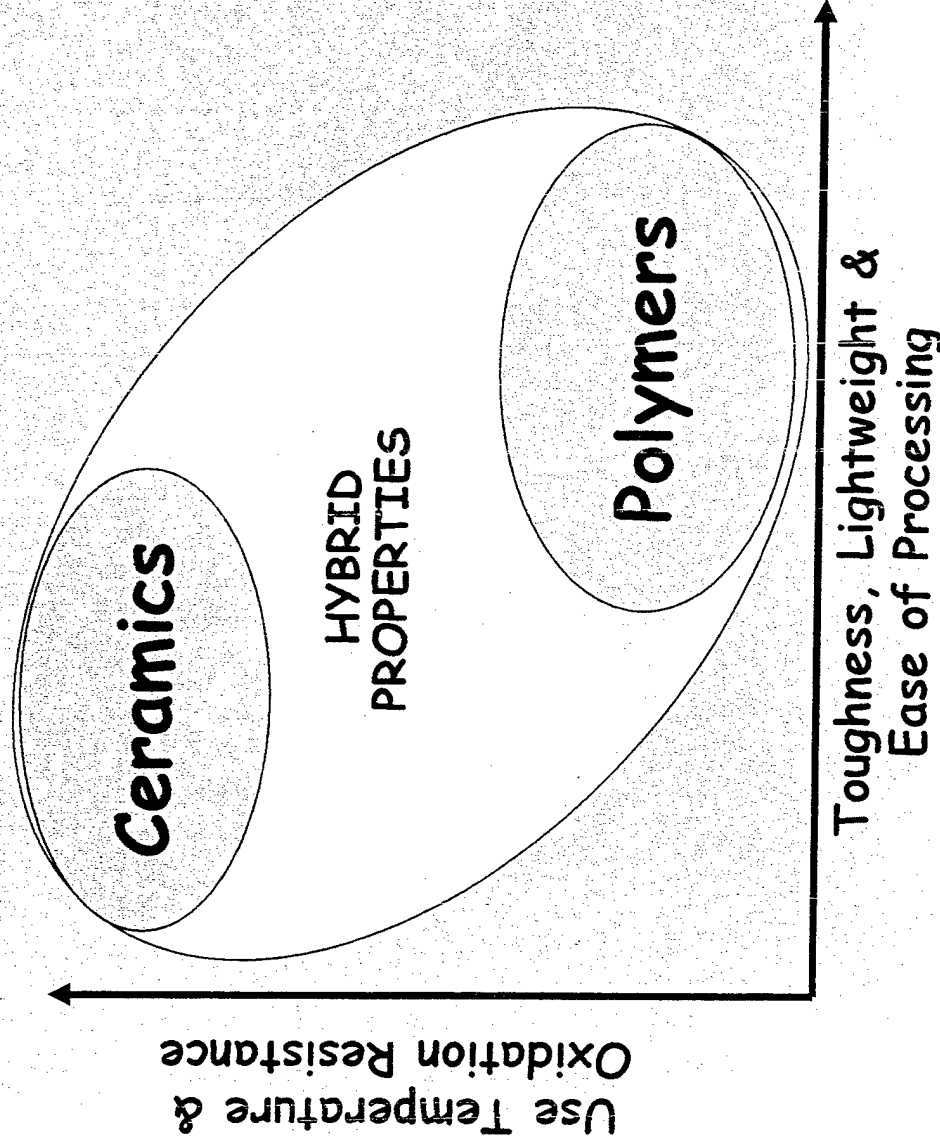
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Hybrid Organic/Organic Owners

Goal: Develop High Performance Polymers that REDEFINE material properties

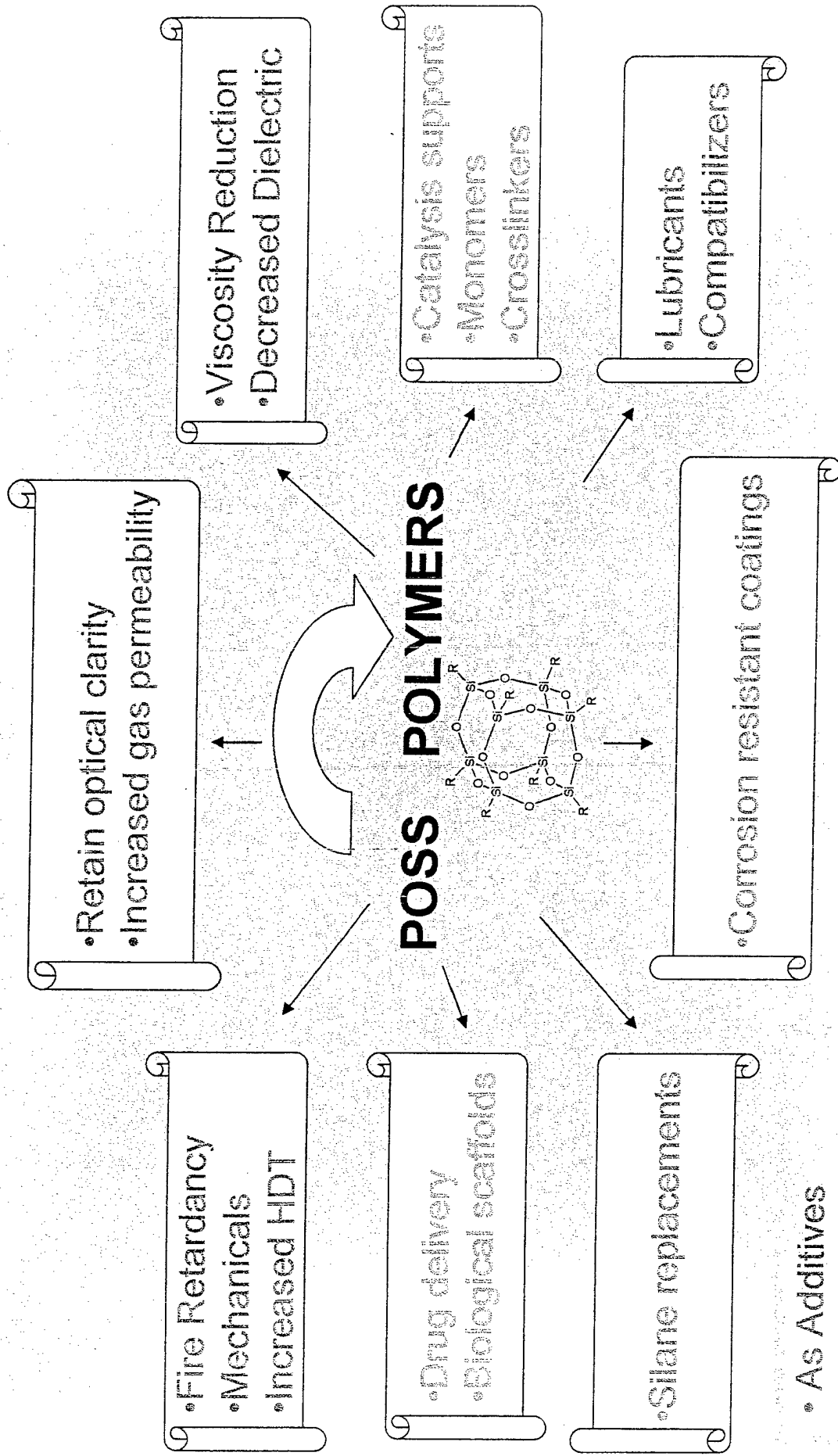
POSS – Polyhedral Oligomeric Silsesquioxanes



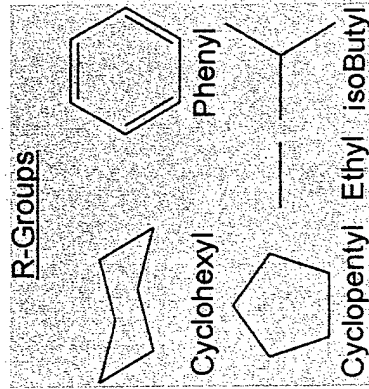
- Hybrid Plastics bridge the differences between ceramics and polymers

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Introduction to POSS

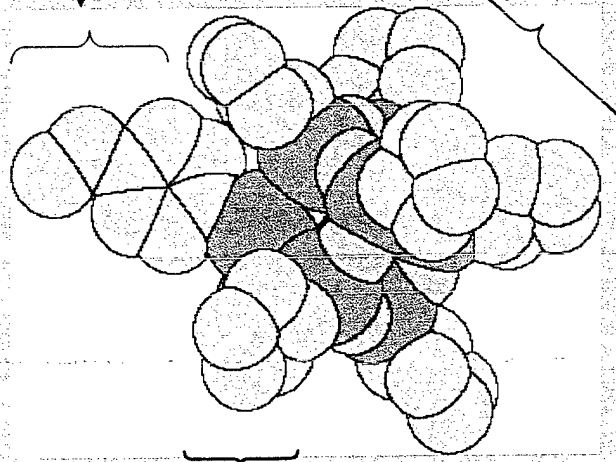


Anatomy of a POSS Nanostructure



Nonreactive organic
(R) groups for
solubilization and
compatibilization.

Nanoscale in size with an
Si-Si distance of 0.5 nm
and a R-R distance of 1.5 nm.

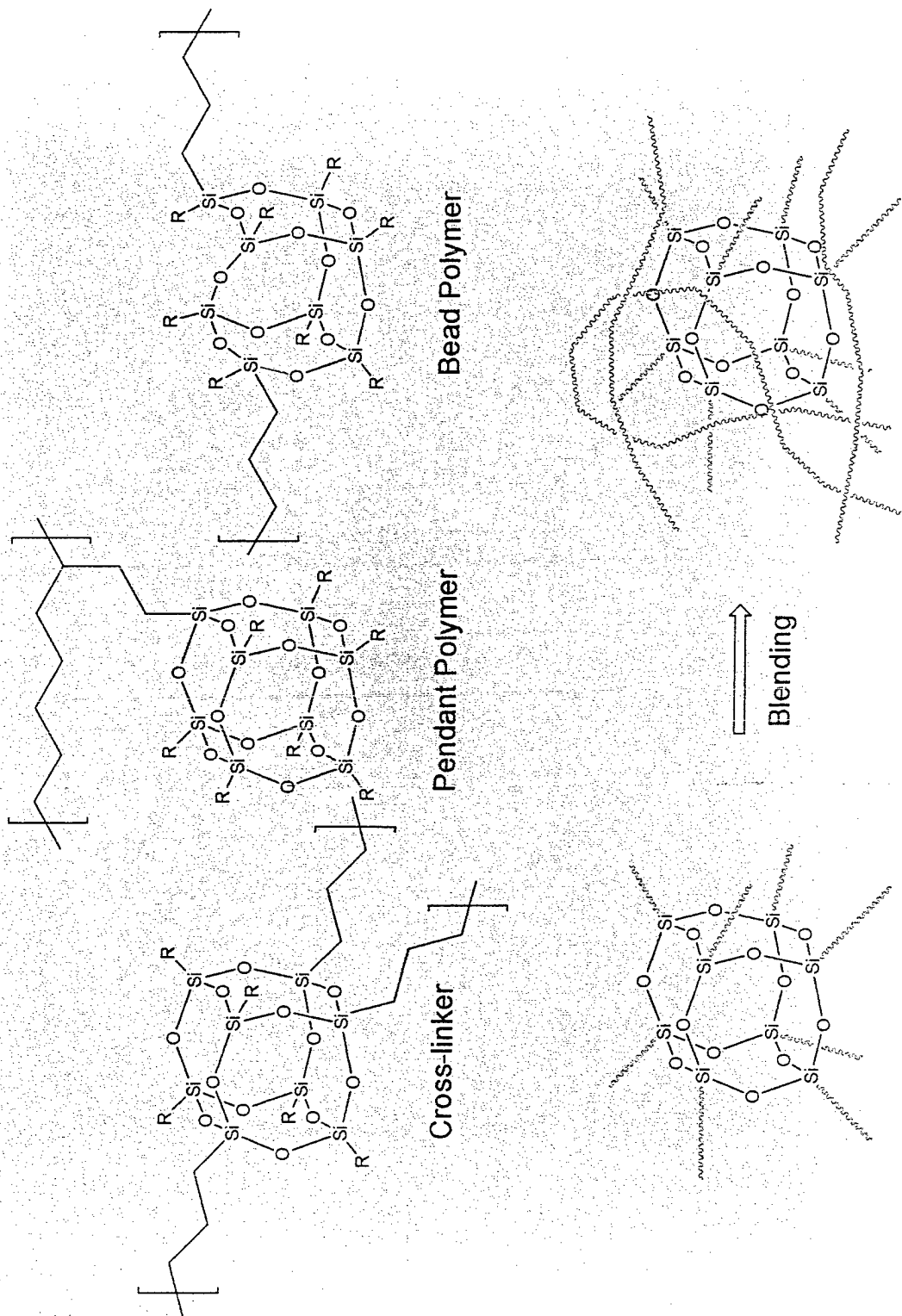


May possess one or more
Functional groups suitable for
Polymerization or grafting.

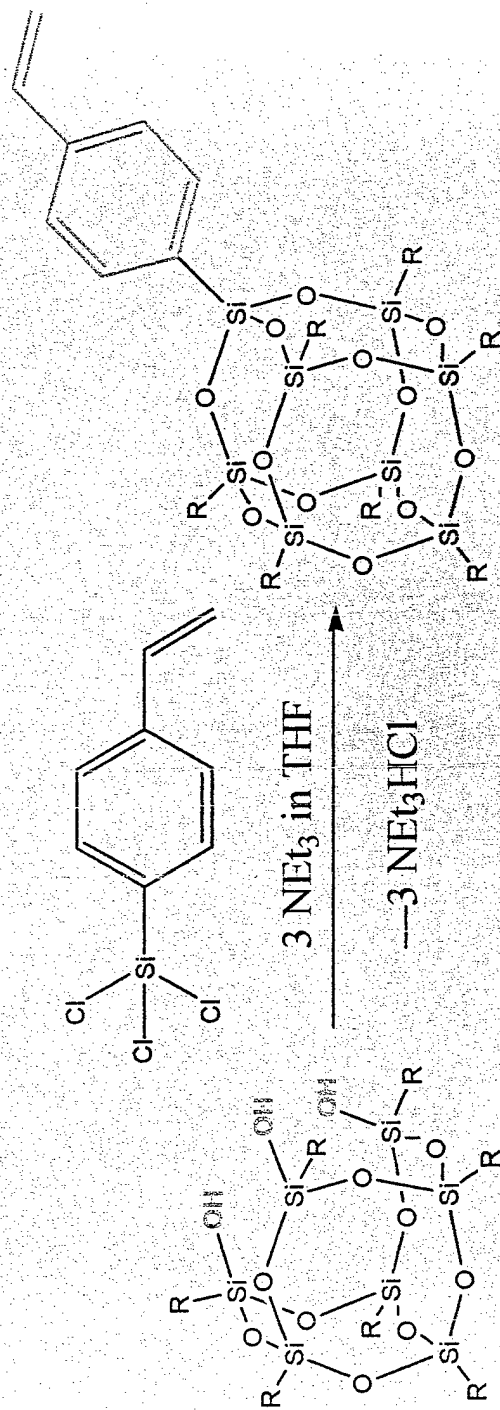
Thermally and chemically
robust hybrid
(organic-inorganic) framework.

Precise three-dimensional structure for molecular level
reinforcement of polymer segments and coils.

POSS Polymer Incorporation

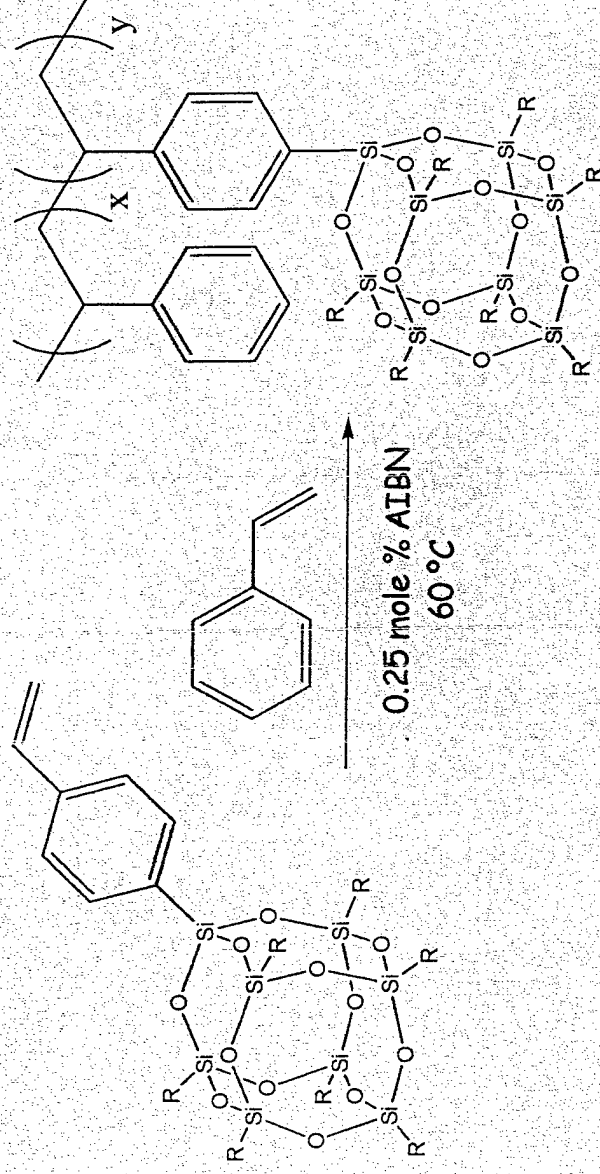


POSS Styrene Monomer Synthesis



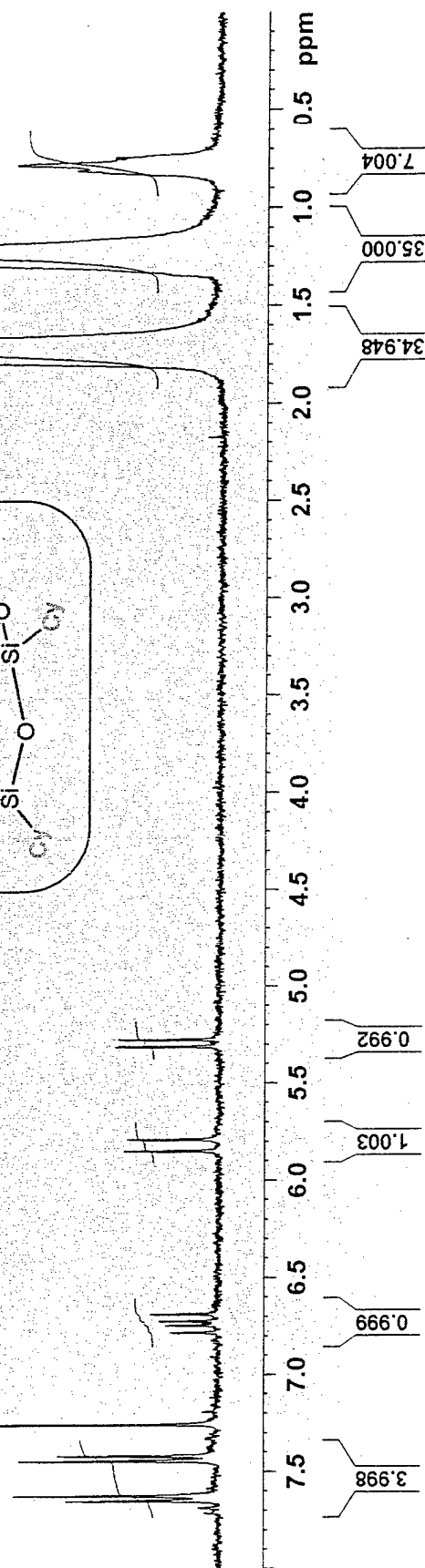
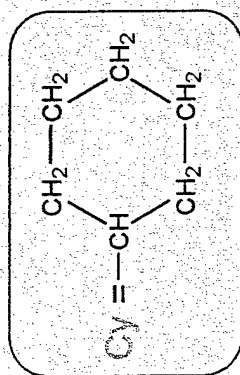
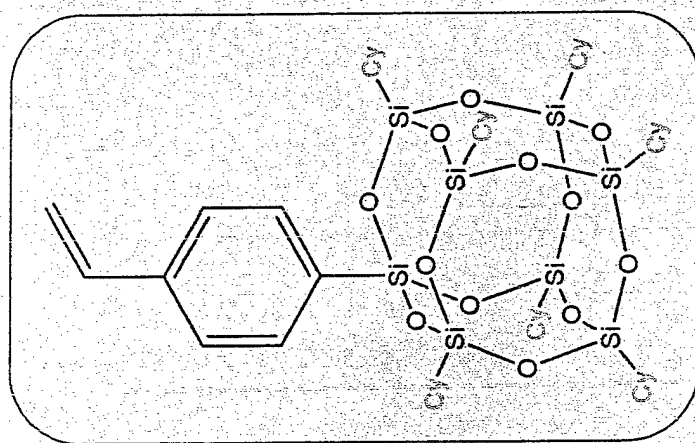
- High-yield syntheses
- Phenyl derivative requires inverse addition
- J. Inorg. Organomet. Polym., Vol 11, 2002, p. 155

POSS-Styrene Copolymer Synthesis



- Solution polymerization in toluene or bulk polymerization possible
- Polymerization is limited by solubility of the POSS-macromer
- Isobutyl-POSS is the most soluble, Phenyl-POSS the least soluble
- Macromolecules Vol. 29, 1996 p. 7302

¹H NMR Cyclohexyl POSS monomer



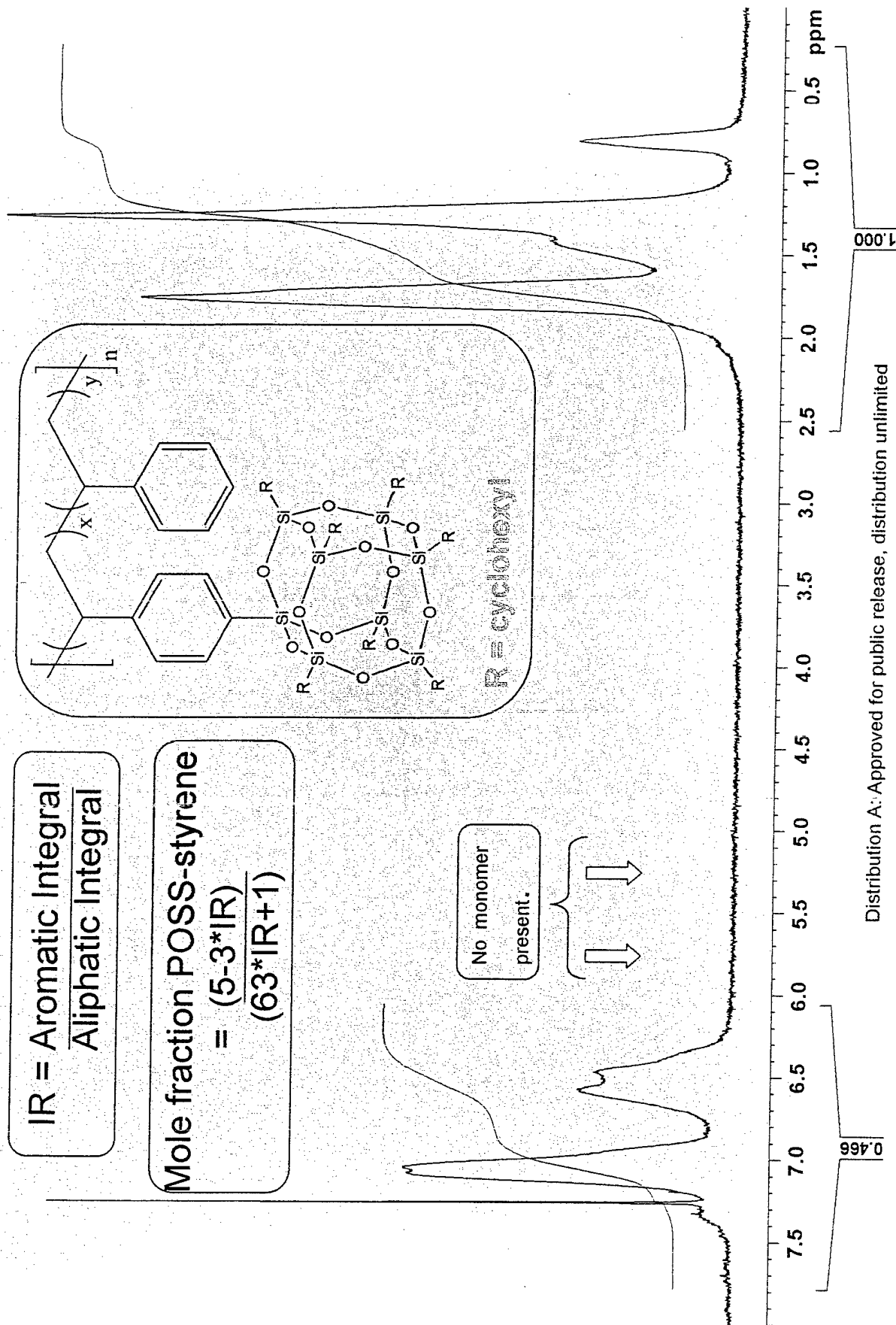
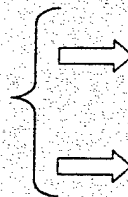
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¹H NMR 50 wt% CyPOSS-PS copolymer

$$\frac{\text{IR} = \text{Aromatic Integral}}{\text{Aliphatic Integral}}$$

$$\begin{aligned} \text{Mole fraction POSS-styrene} \\ = \frac{(5-3 \cdot \text{IR})}{(63 \cdot \text{IR} + 1)} \end{aligned}$$

No monomer
present.



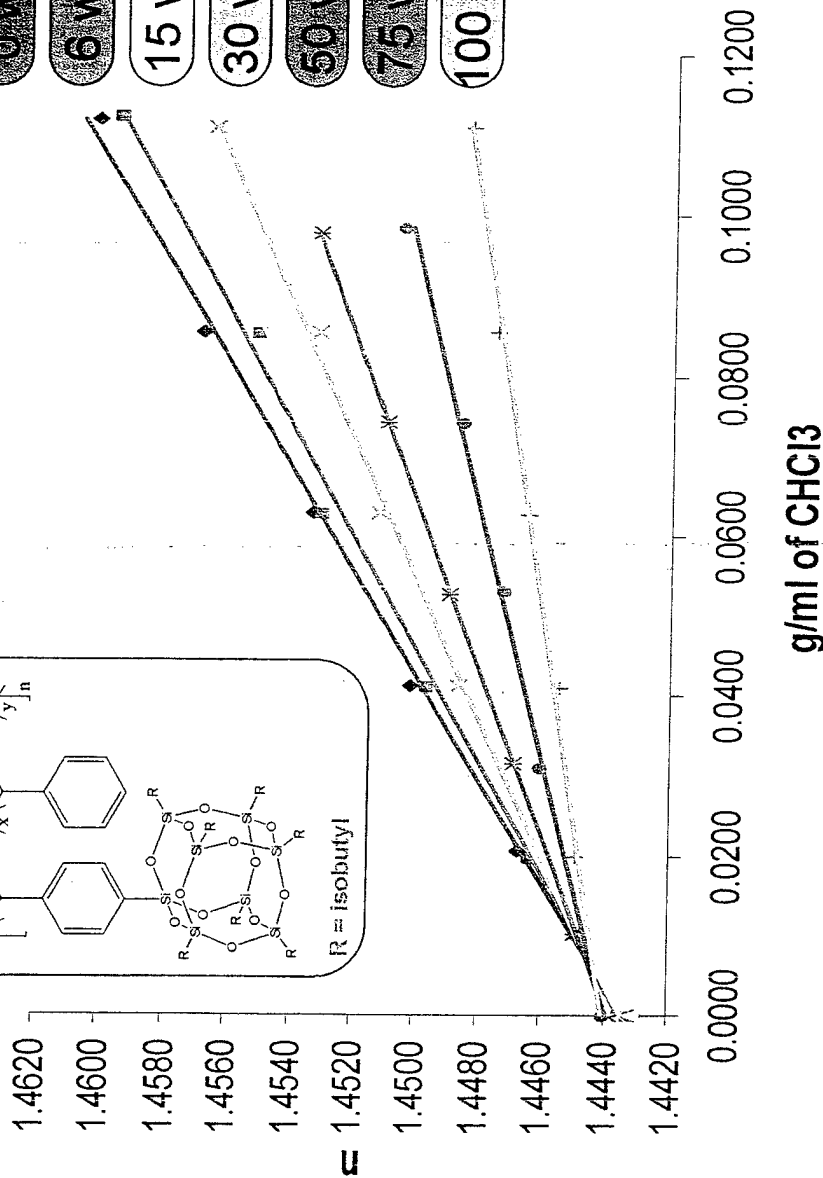
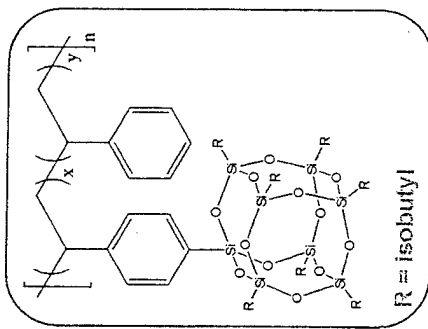
The Specific Refractive Index Increment and Possibilities

- The Specific Refractive Index Increment, $dn/dc = (n - n_0)/c$, is the change in RI with change in concentration.
- It is a constant value for a dilute polymer in solution at constant temperature, pressure and wavelength.
- It is useful for determining the M_w of a polymer by light scattering (GPC).
- For copolymers composed of two monomers, the dn/dc is an additive function of the individual weight fractions.

WAYFIND THE dn/dc VALUES?

- To accurately determine the weight average molecular weights of various POSS-polymers.
- To generically parameterize each POSS type (R = cyclohexyl, isobutyl, phenyl etc.) in order to predict POSS-polymer dn/dc values.
- To provide a quick and accurate method to determine POSS % incorporation in any polymer system.

RI vs Concentration of BIP-POSS-PS copolymer



wt.% POSS-Styrene

Slope = dn/dc

$$Y = 0.1327x + 1.4434$$

$$R^2 = 0.9955$$

$$Y = 0.1428x + 1.4435$$

$$R^2 = 0.9958$$

$$Y = 0.1327x + 1.4436$$

$$R^2 = 0.9929$$

$$Y = 0.1159x + 1.4437$$

$$R^2 = 0.9976$$

$$Y = 0.0954x + 1.4439$$

$$R^2 = 0.9999$$

$$Y = 0.0636x + 1.444$$

$$R^2 = 0.9962$$

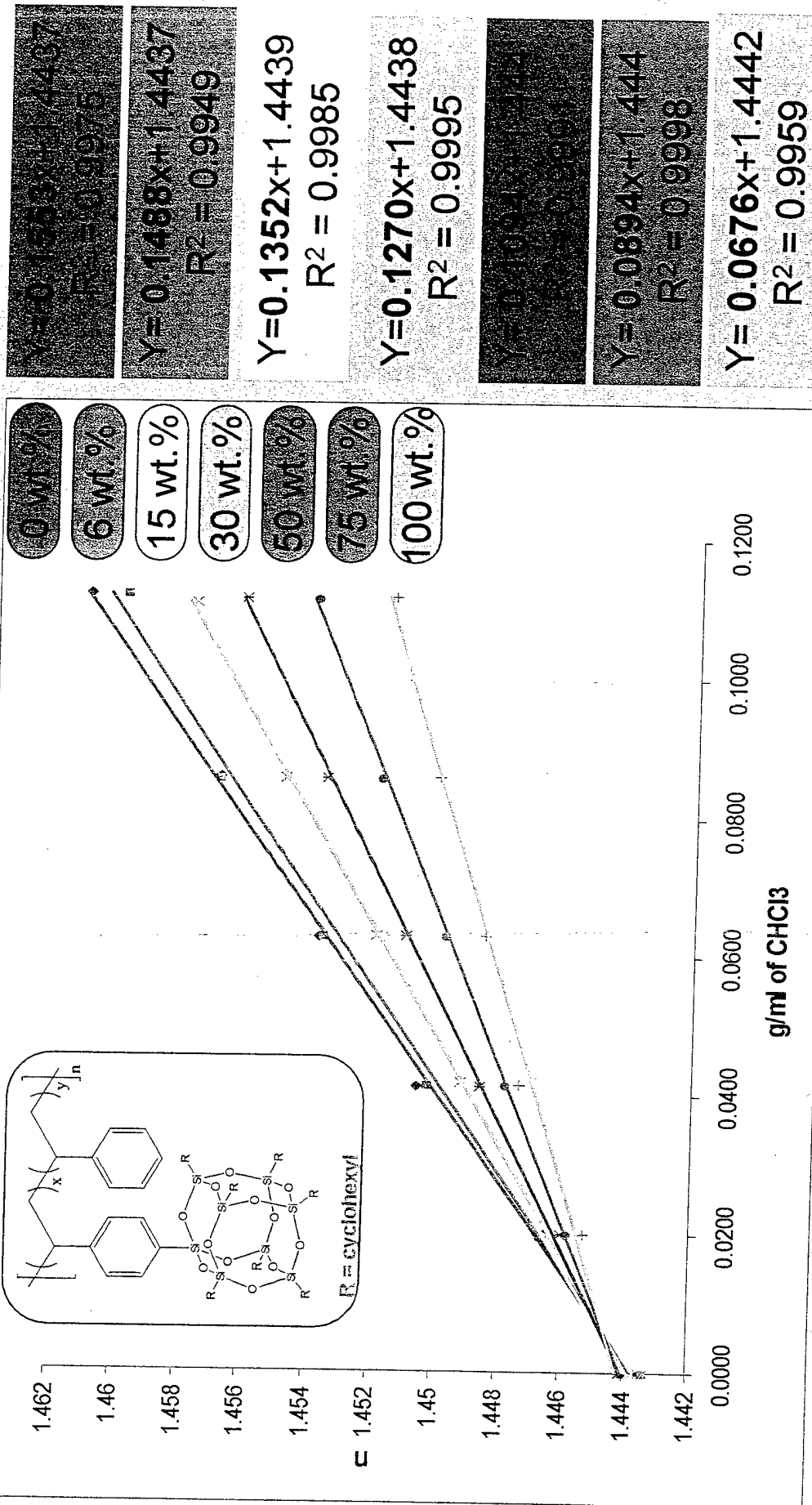
$$Y = 0.0402x + 1.444$$

$$R^2 = 0.9976$$

RI vs. Concentration of CyPOSS-PS copolymer

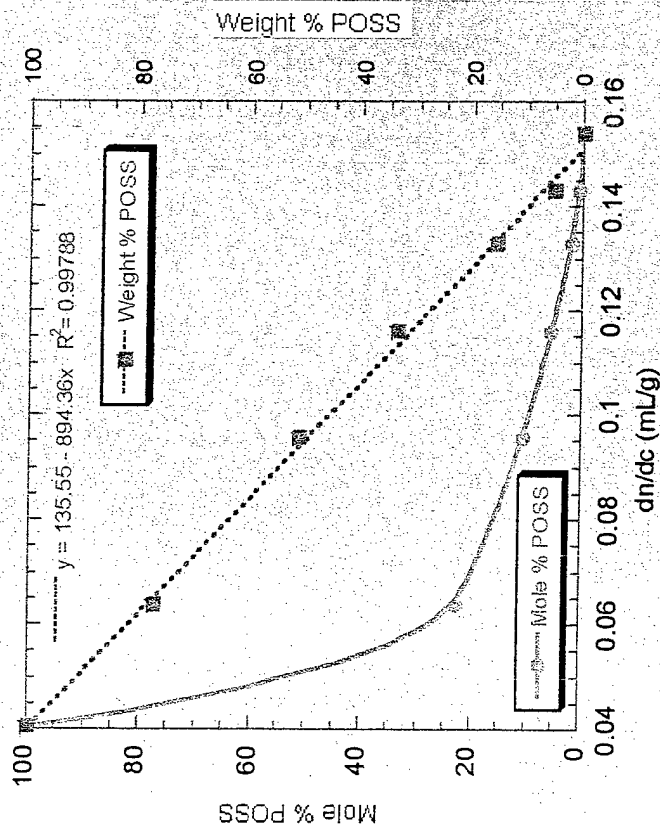
wt.% POSS-Styrene

Slope = dn/dc

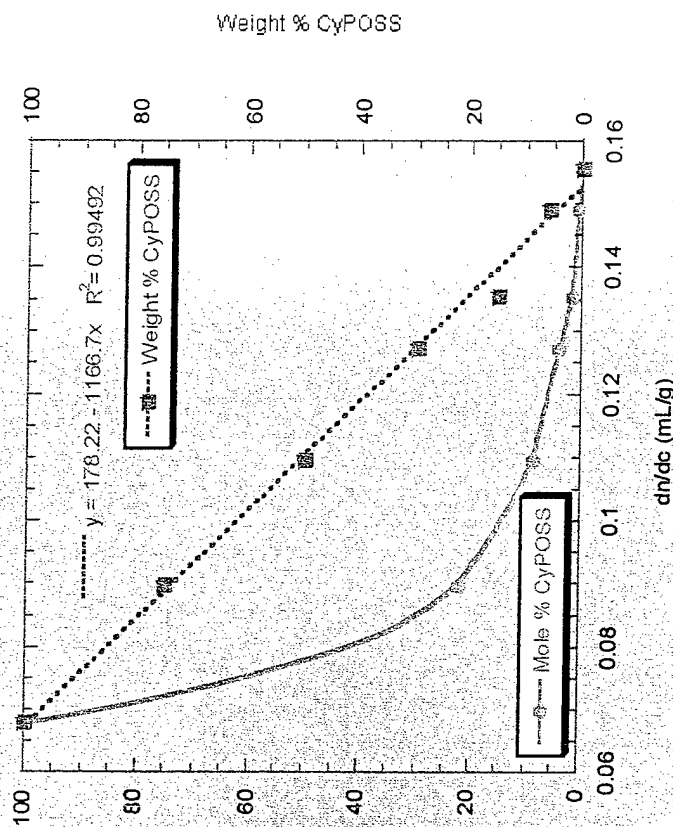


dn/dc vs wt% and mole%

iBuPOSS-PS copolymer



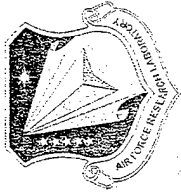
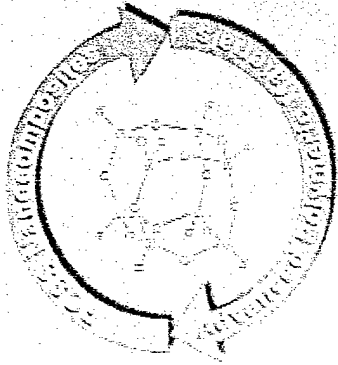
CyPOSS-PS copolymer



- Clearly, dn/dc is linear with respect to weight % POSS not mole % POSS; changes in refractive index are proportional to the volume occupied by the polymeric components. A typical POSS monomer is about 10X more massive than a typical organic monomer.
- Note that the dn/dc value decreases with increasing POSS incorporation.

Summary & Future Work

- There is a linear relationship between weight % POSS and the dn/dc of a styrene copolymer.
- To graph a dn/dc / weight % POSS relationship for any new POSS polymer it is reasonable to just measure the dn/dc values of the 0 and 100 % POSS polymer.
- We intend to prove this concept for other glassy (Acrylics) and rubbery (Norbornenes) POSS copolymers.



The POSS-Polymer Working Group Air Force Research Lab - Edwards

- | | |
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